

EAST Search History**EAST Search History (I nterference)**

Ref #	Hits	Search Query	DBs	Default Operator	Plurals	Time Stamp
S57	0	((substrate or wafer or under\$4layer or (bottom near4 layer)) same (photoresist or resist or photo\$4cur\$4 or photo\$3imageable) same (novolac or epoxy or resin) same photoactive same (carbonyl near4 acid near8 (generat\$4 or liberat\$4)) same (expos\$4 or illuminat\$4 or irradiat\$4)) and develop\$4 and ((solubilization or solubilizing or soluble or solubility or insoluble) same (prevent\$4 or caus\$4 or inhibit\$4))	USPAT; UPAD	OR	ON	2010/09/01 15:17
S58	0	((substrate or wafer or under\$4layer or (bottom near4 layer)) same (photoresist or resist or photo\$4cur\$4 or photo\$3imageable) same (novolac or epoxy or resin) same photoactive same (carbonyl near4 acid near8 (generat\$4 or liberat\$4)) same (expos\$4 or illuminat\$4 or irradiat\$4)) and develop\$4 and ((solubilization or solubilizing or	USPAT; UPAD	OR	ON	2010/09/01 15:19

		soluble or solubility or insoluble) same (prevent\$4 or caus \$4 or inhibit\$4 or enhance\$5 or increase))			
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\ 10687288.wsp**